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Development of tin oxide/copper(I) oxide heterojunction solar cell

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The rapid expansion of the global population together with industrialization intensifies our diurnal energy need. Addressing the present energy demand is a challenging task. Solar energy stands as a pivotal solution to the global energy crisis, offering a sustainable and renewable energy source to meet the escalating demand for electricity. Photovoltaic energy emerges as a favorable substitute due to its widespread availability, free accessibility, eco-friendly nature, and reduced operational and maintenance expenses. However, the markedly available photovoltaics are unaffordable to the public due to their expensiveness. Accordingly, this study focuses on the development of a low-cost eco-friendly tin oxide (SnO₂)-based heterojunction solar cell, aiming to enhance photovoltaic performance through systematic fabrication and optimization processes. The Cu/n-SnO₂/p-Cu₂O/Au heterojunction solar cell was fabricated using the method of electrodeposition. Tin (IV) Oxide (SnO₂) was employed as the n-type material and Copper(I) Oxide (Cu₂O) as the p-type material. The fabrication process involved the electrodeposition of n-type SnO₂ thin film on copper (Cu) substrates, followed by subsequent deposition of p-type copper(I) oxide (Cu₂O) thin film. For making front contacts to the heterojunction, thin Au spots (area $\sim 2 \times 2 \text{ mm}^2$) were sputtered onto the p-Cu₂O thin film of the bilayer. The back contact of the solar cell was the Cu substrate. The photoresponses of the Cu/n-SnO₂/p-Cu₂O/Au solar cell structure were monitored by optimizing the bath temperature of the SnO₂ film deposition bath. Electrodeposition of SnO₂ layers was performed on copper substrates in a three-electrode electrochemical cell using a solution containing 30 mM SnCl₂ and 150 mM HNO₃ and electrodeposition was conducted at -0.85 V vs. Ag/AgCl for 2 min at temperature values of 70 °C, 75 °C, 80 °C, 85 °C, and 90 °C. To fabricate the device a p-Cu₂O thin film was electrodeposited on Cu/n-SnO₂ film at -0.45 V vs. Ag/AgCl for 40 min in a three-electrode electrochemical cell containing 0.1 M CuSO₄, 3 M C₃H₆O₃, and NaOH aqueous solution. The temperature and pH of the bath were maintained at 60 °C and 13 respectively. The results of photoresponse measurements together with current-voltage measurements were used to optimize the solar cell. The highest photoresponses resulted for the SnO₂ thin films deposited at a bath temperature value of 85 °C. This research contributes to the advancement of tin oxide-based heterojunction solar cell technology and offers insights for future optimization and development efforts in renewable energy generation.

Keywords: Cu₂O, Electrodeposition, Heterojunction, Photovoltaic, SnO₂

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